# Polycrystalline diamond (PCD) Grade: CTX002

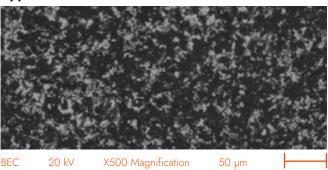


### Key material characteristics

- 2 µm diamond grain size
- 13 % cobalt ratio (wt %)
- High chip resistance

ldeal for profile routers and thread cutting tools, can also be used in wear part applications. 2  $\mu m$  average grain size with increased cobalt for ease of processing. CTX002 is ideal for complex tools where intensive processing is required.

#### Typical microstructure



	Behaviour i	n application	Processing characteristics		
<b>Grade</b> Grain size	Chip resistance	Abrasion resistance	Electro-discharge machinability	Grindability	
<b>CMX850</b> 0.85 μm					
<b>CTX002</b> 2 μm					
<b>CTB004</b> 4 μm					
<b>CTB010</b> 10 μm					
<b>CTH025</b> 25 μm					
<b>CTM302</b> 2 - 30 μm					

Size and format available								
Maximum disc diamete	er: 76 mm	: 76 mm Maximum PCD certified area: 70 mm						
				Overa	l height			
PCD layer thickness	0.8	1.0	1.2	1.4	1.6	2.0	3.18	8.0
0.5		<b>/</b>			<b>/</b>		<b>/</b>	

## Material characteristics



Physical and metallurgical properties					
Property	Measurement	Applicable standard			
Transverse rupture strenght characteristic strengh (MPa)	2175	- ACTAA C1000			
Weibull modulus	7.1	- ASTM C1239			
Fracture toughness mean (MPa.m <sup>½</sup> )	9.12	Shetty et al. (1995)			
Elastic modulus (GPa)	950	AOTA 4 F 40 4			
Poisson's ratio	0.1	ASTM E494			
Density (g/cm³)	4.36	Archimedes principle			
Thermal conductivity (W/m/K) at 500 °C	304.3	Calculated from thermal diffusivity, specific heat capacity and density			
Knoop hardness (Indentation)(GPa)	45	ASTM C1326-03			

	Superior	Advanced	Assured
Polish quality	P+	P1	P2
Overall height tolerance + mm	<b>H+</b> 0.025	<b>H1</b> 0.05	<b>H2</b> 0.1
PCD layer tolerance + mm	<b>L+</b> 0.1	<b>L1</b> 0.15	<b>L2</b> 0.2

Range	PCD layer (mm)	Certified area (mm)	Overall height (mm)	Nomenclature	Item number
Advanced	0.5	70	1.6	CTX002 R70-160-05 P1H1L+	176-200-0043-01
Advanced	0.5	70	0.8	CTX002 R70-080-05 P1H1L+	176-200-0052-01
Advanced	0.5	70	1.0	CTX002 R70-100-05 P1H1L+	176-200-0049-01
Advanced	0.5	70	1.2	CTX002 R70-120-05 P1H1L+	176-200-0048-01
Advanced	0.5	70	1.6	CTX002 R70-140-05 P1H1L+	176-200-0054-01
Advanced	0.5	70	2.0	CTX002 R70-200-05 P1H1L+	176-200-0046-01
Advanced	0.5	70	3.18	CTX002 R70-318-05 P1H1L+	176-200-0047-01
Assured	0.5	68	1.6	CTX002 R68-160-05 P2H2L1	176-200-0042-01
Assured	0.5	68	2.0	CTX002 R68-200-05 P2H2L1	176-200-0045-01
Assured	0.5	68	3.18	CTX002 R68-318-05 U1H2L1	176-200-0056-01
Assured	0.5	68	1.6	CTX002 R68-160-05 U1H2L1	176-200-0058-01
Advanced	0.5	60	1.6	CTX002 R60-160-05 P1H1L1	176-200-0044-01





Element Six PCD disc and segments



Element Six is a global leader in the development and production of synthetic diamond and tungsten carbide solutions. For over 70 years, our innovation expertise has enabled a wide range of industries, from aerospace and mining, to semiconductors and sensing. Part of the De Beers Group, our primary manufacturing sites are located in the US, UK, Ireland, Germany and South Africa. Our sites in Ireland and Germany are ISO 50001 certified.

Through the De Beers Group, Element Six is a member of the UN Global Compact (UNGC). The UNGC drives business awareness and action towards the UN Sustainable Development Goals (SDGs), focussing on 10 principles around human rights, labour, environment and anti-corruption. Element Six works within the De Beers Group Building Forever commitment and Science Based Target Initiative (STBi), which is also based on the UNGC principles.

We incorporate and take responsibility for these principles through the Element Six Code of Conduct, Our Values, Responsibilities and Policies.

At Element Six, we have active communities working towards sustainability from a variety of angles, such as environmental impact, inclusion, diversity and community outreach, both internally and externally.

## Contact us

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